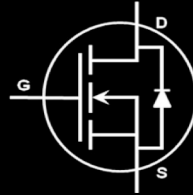


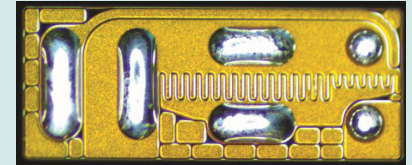
# EPC8010 – Enhancement Mode Power Transistor

 $V_{DS}, 100\text{ V}$ 

New Product

 $R_{DS(on)}, 160\text{ m}\Omega$ 
 $I_D, 2.7\text{ A}$ 


Gallium Nitride is grown on Silicon Wafers and processed using standard CMOS equipment leveraging the infrastructure that has been developed over the last 55 years. GaN's exceptionally high electron mobility and low temperature coefficient allows very low  $R_{DS(on)}$ , while its lateral device structure and majority carrier diode provide exceptionally low  $Q_G$  and zero  $Q_{RR}$ . The end result is a device that can handle tasks where very high switching frequency, and low on-time are beneficial as well as those where on-state losses dominate.



EPC8010 eGaN FETs are supplied only in passivated die form with solder bars

Maximum Ratings			
$V_{DS}$	Drain-to-Source Voltage (Continuous)	100	V
$I_D$	Continuous ( $T_A = 25^\circ\text{C}$ , $R_{\theta JA} = 57^\circ\text{C/W}$ )	2.7	A
	Pulsed ( $25^\circ\text{C}$ , $T_{Pulse} = 300\ \mu\text{s}$ )	7.5	
$V_{GS}$	Gate-to-Source Voltage	6	V
	Gate-to-Source Voltage	-4	
$T_J$	Operating Temperature	-40 to 150	$^\circ\text{C}$
$T_{STG}$	Storage Temperature	-40 to 150	

### Applications

- Ultra High Speed DC-DC Conversion
- RF Envelope Tracking
- Wireless Power Transfer
- Game Console and Industrial Movement Sensing (LiDAR)

### Benefits

- Ultra High Efficiency
- Ultra Low  $R_{DS(on)}$
- Ultra Low  $Q_G$
- Ultra Small Footprint

Static Characteristics ( $T_J = 25^\circ\text{C}$ unless otherwise stated)						
PARAMETER	TEST CONDITIONS	MIN	TYP	MAX	UNIT	
$BV_{DSS}$	Drain-to-Source Voltage	$V_{GS} = 0\text{ V}$ , $I_D = 125\ \mu\text{A}$	100		V	
$I_{DSS}$	Drain Source Leakage	$V_{GS} = 0\text{ V}$ , $V_{DS} = 80\text{ V}$	20	100	$\mu\text{A}$	
$I_{GSS}$	Gate-to-Source Forward Leakage	$V_{GS} = 5\text{ V}$	0.1	0.5	$\text{mA}$	
	Gate-to-Source Reverse Leakage	$V_{GS} = -4\text{ V}$	20	100	$\mu\text{A}$	
$V_{GS(TH)}$	Gate Threshold Voltage	$V_{DS} = V_{GS}$ , $I_D = 0.25\text{ mA}$	0.8	1.4	V	
$R_{DS(on)}$	Drain-Source On Resistance	$V_{GS} = 5\text{ V}$ , $I_D = 0.5\text{ A}$	120	160	$\text{m}\Omega$	
$V_{SD}$	Source-Drain Forward Voltage	$I_S = 0.5\text{ A}$ , $V_{GS} = 0\text{ V}$	2.5		V	

Specifications are with substrate shorted to source where applicable.

Thermal Characteristics			
		TYP	UNIT
$R_{\theta JC}$	Thermal Resistance, Junction to Case	8.2	$^\circ\text{C/W}$
$R_{\theta JB}$	Thermal Resistance, Junction to Board	16	$^\circ\text{C/W}$
$R_{\theta JA}$	Thermal Resistance, Junction to Ambient (Note 1)	82	$^\circ\text{C/W}$

Note 1:  $R_{\theta JA}$  is determined with the device mounted on one square inch of copper pad, single layer 2 oz copper on FR4 board. See [http://epc-co.com/epc/documents/product-training/Appnote\\_Thermal\\_Performance\\_of\\_eGaN\\_FETs.pdf](http://epc-co.com/epc/documents/product-training/Appnote_Thermal_Performance_of_eGaN_FETs.pdf) for details.

Dynamic Characteristics (T<sub>J</sub> = 25°C unless otherwise stated)

PARAMETER		TEST CONDITIONS	MIN	TYP	MAX	UNIT
C <sub>ISS</sub>	Input Capacitance	V <sub>DS</sub> = 50 V, V <sub>GS</sub> = 0 V		43	55	pF
C <sub>OSS</sub>	Output Capacitance			25	36	
C <sub>RSS</sub>	Reverse Transfer Capacitance			0.3	0.5	
R <sub>G</sub>	Gate Resistance			0.3		Ω
Q <sub>G</sub>	Total Gate Charge	V <sub>DS</sub> = 50 V, V <sub>GS</sub> = 5 V, I <sub>D</sub> = 1 A		360	480	pC
Q <sub>GS</sub>	Gate-to-Source Charge	V <sub>DS</sub> = 50 V, I <sub>D</sub> = 1 A		130		
Q <sub>GD</sub>	Gate-to-Drain Charge			60	100	
Q <sub>G(TH)</sub>	Gate Charge at Threshold			100		
Q <sub>OSS</sub>	Output Charge	V <sub>DS</sub> = 50 V, V <sub>GS</sub> = 0 V		2200	3300	
Q <sub>RR</sub>	Source-Drain Recovery Charge			0		

Specifications are with substrate shorted to source where applicable.

Figure 1: Typical Output Characteristics at 25°C

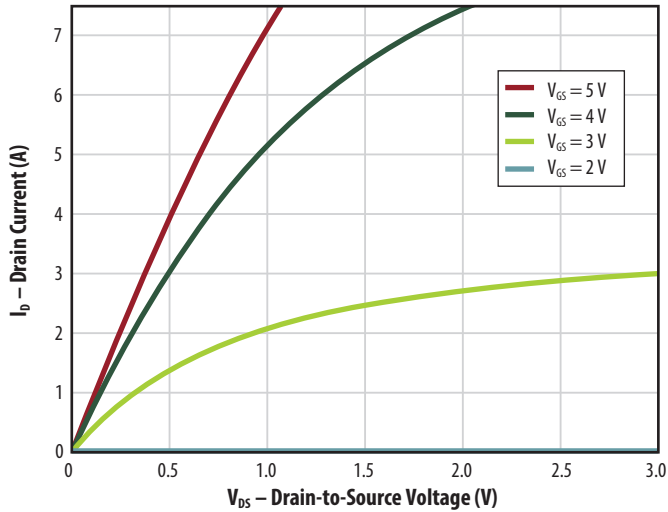


Figure 2: Transfer Characteristics

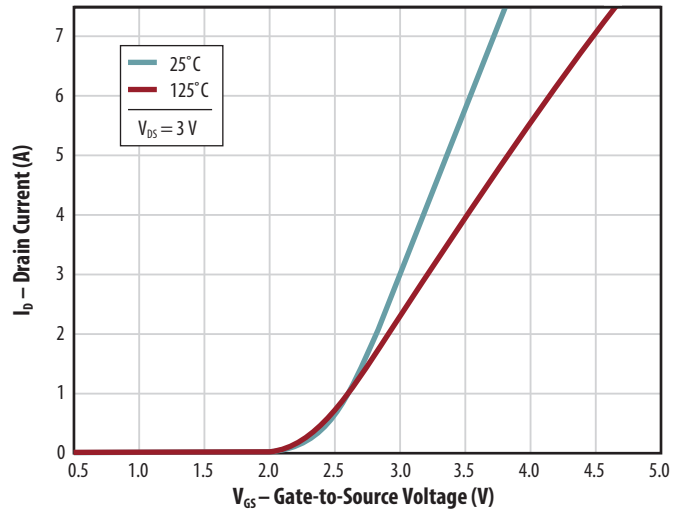


Figure 3: R<sub>DS(on)</sub> vs. V<sub>GS</sub> for Various Drain Currents

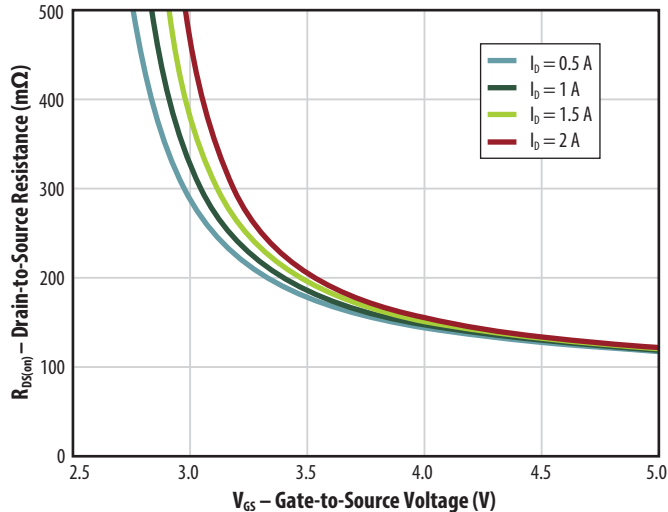


Figure 4: R<sub>DS(on)</sub> vs. V<sub>GS</sub> for Various Temperatures

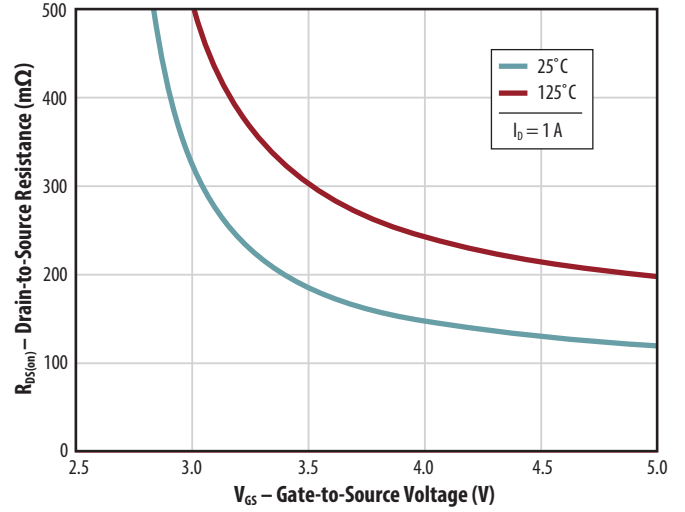


Figure 5a: Capacitance (Linear Scale)

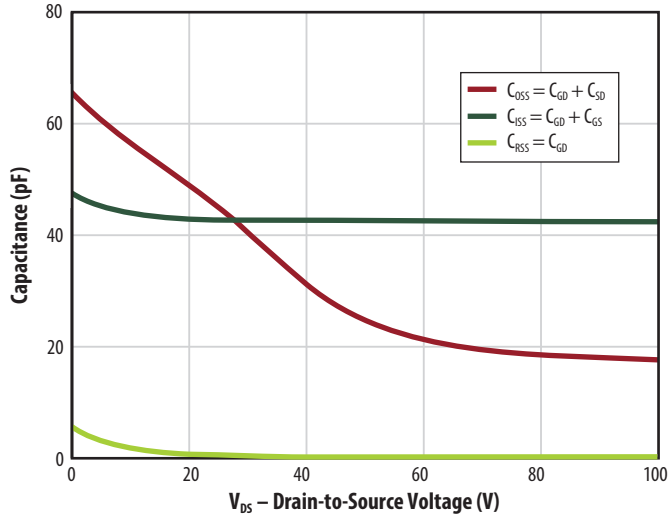


Figure 5b: Capacitance (Log Scale)

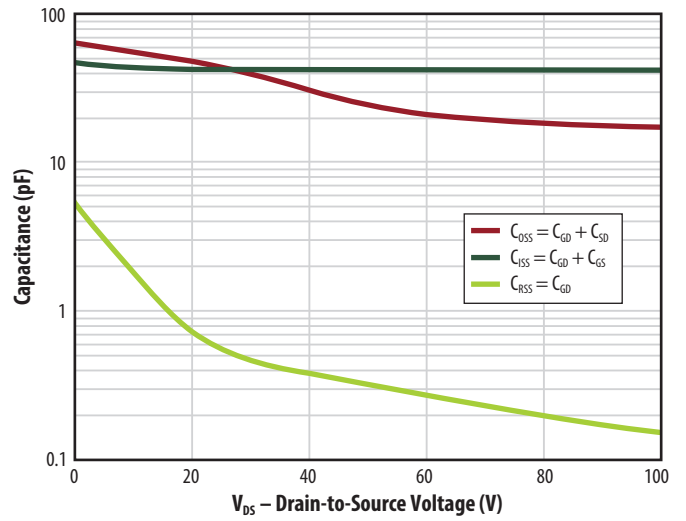


Figure 6: Gate Charge

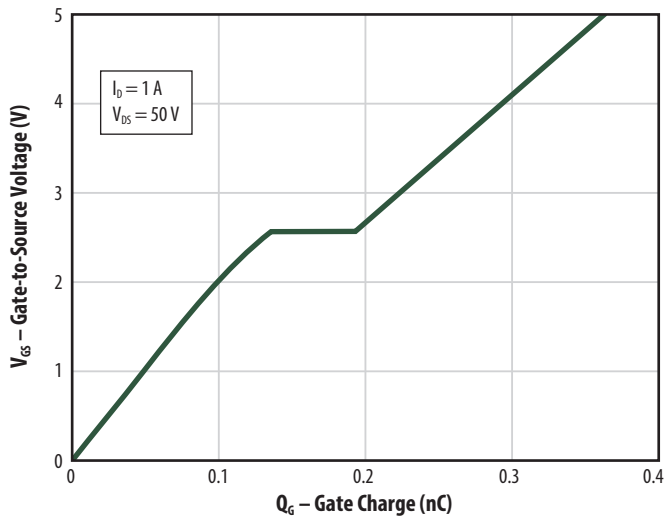


Figure 7: Reverse Drain-Source Characteristics

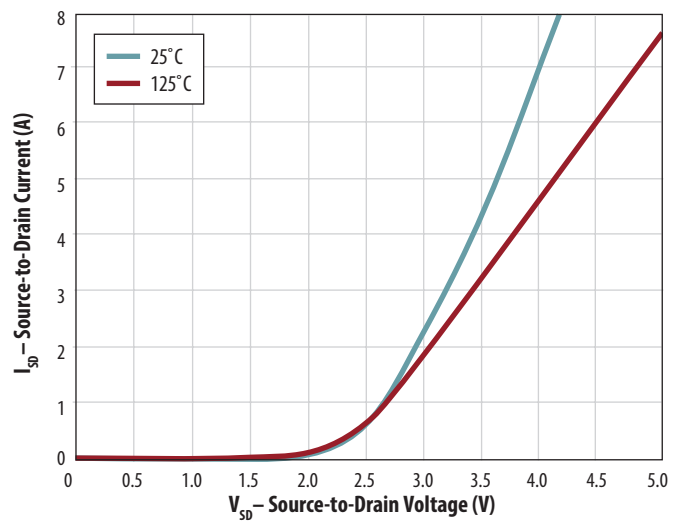


Figure 8: Normalized On-State Resistance vs. Temperature

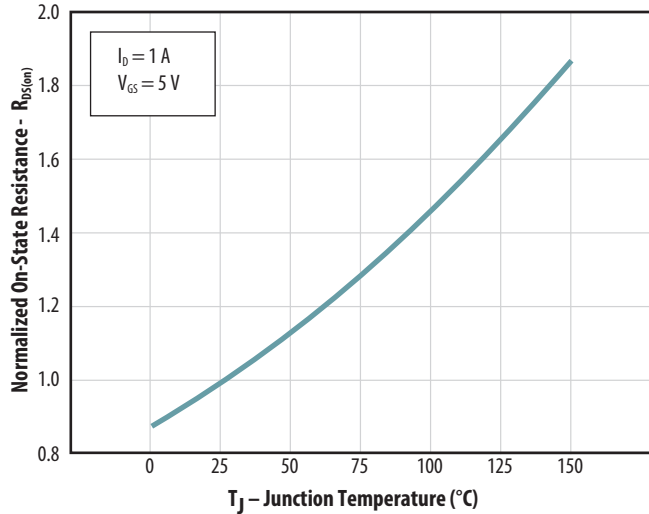


Figure 9: Normalized Threshold Voltage vs. Temperature

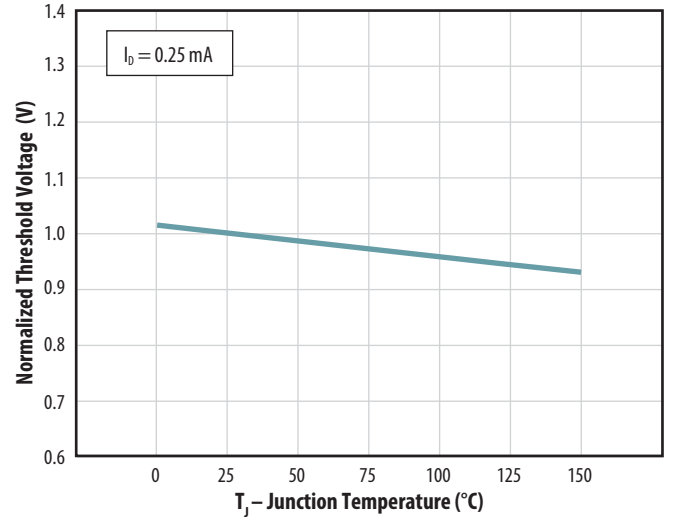


Figure 10: Gate Leakage Current

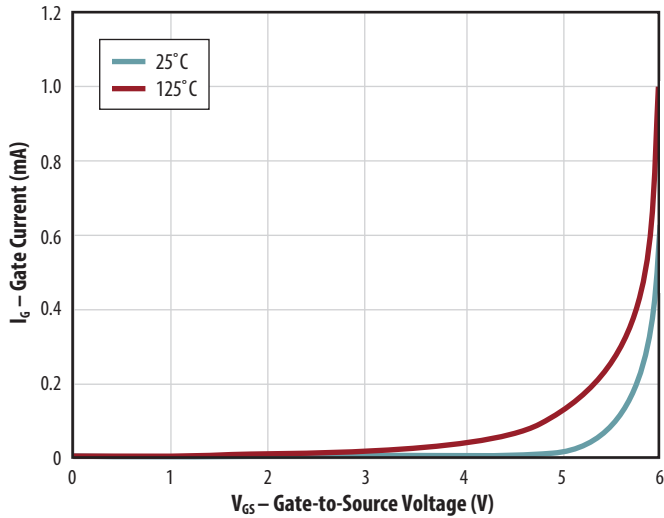
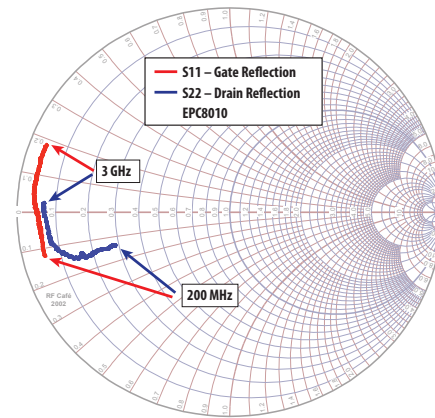


Figure 11: Smith Chart

S-Parameter Characteristics  
 $V_{GSQ} = 1.34 \text{ V}$ ,  $V_{DSQ} = 50 \text{ V}$ ,  $I_{DQ} = 0.50 \text{ A}$   
 Pulsed Measurement, Heat-Sink Installed,  $Z_0 = 50 \Omega$



All measurements were done with substrate shorted to source.

Figure 12: Gain Chart

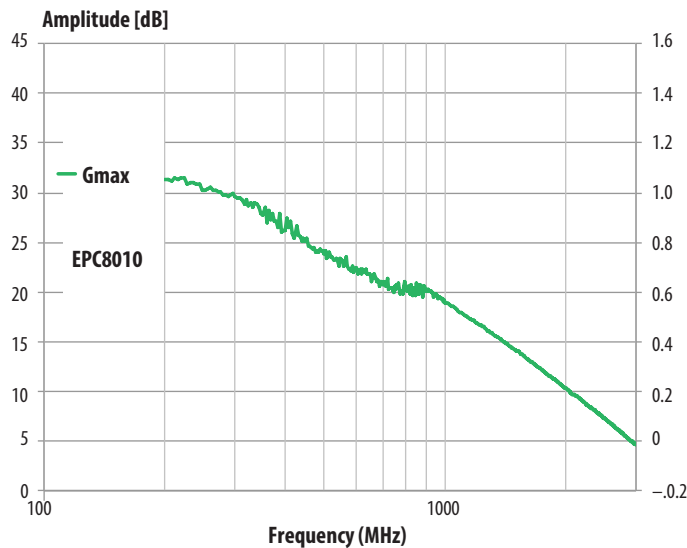


Figure 13: Device Reflection

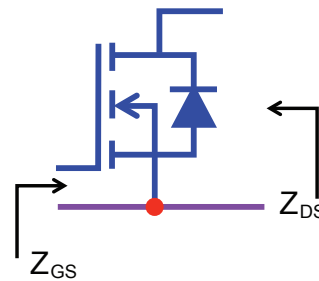
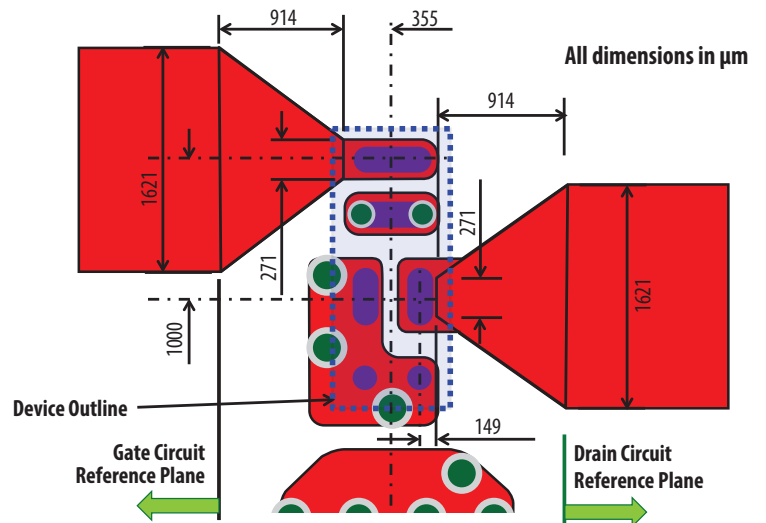


Figure 14: Taper and Reference Plane details – Device Connection

Micro-Strip design: 2-layer  
 1/2 oz (17.5 μm) thick copper  
 30 mil thick R04350 substrate



Frequency [MHz]	Gate ( $Z_{GS}$ ) [Ω]	Drain ( $Z_{DS}$ ) [Ω]
200	2.54 - j11.18	22.54 - j23.91
500	1.57 - j4.20	6.01 - j15.53
1000	0.94 - j0.23	1.85 - j6.89
1200	0.97 + j0.89	1.47 - j4.87
1500	0.97 + j2.38	1.51 - j2.52
2000	1.08 + j4.80	2.09 + j0.41
2400	1.21 + j6.74	2.50 + j2.25
3000	1.62 + j10.34	3.05 + j5.00

S-Parameter Table - Download S-parameter files at [www.epc-co.com](http://www.epc-co.com)

Figure 15: Transient Thermal Response Curves

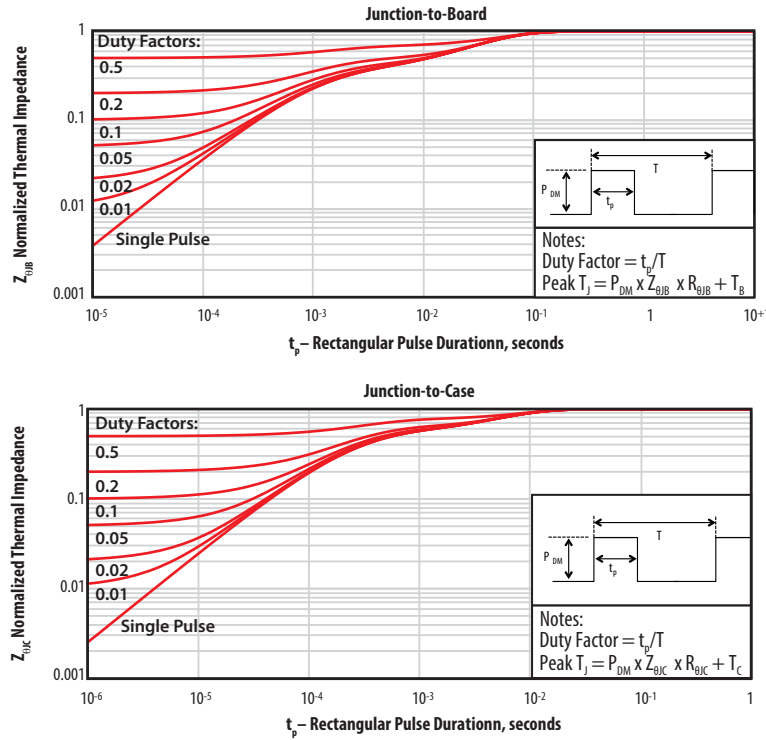
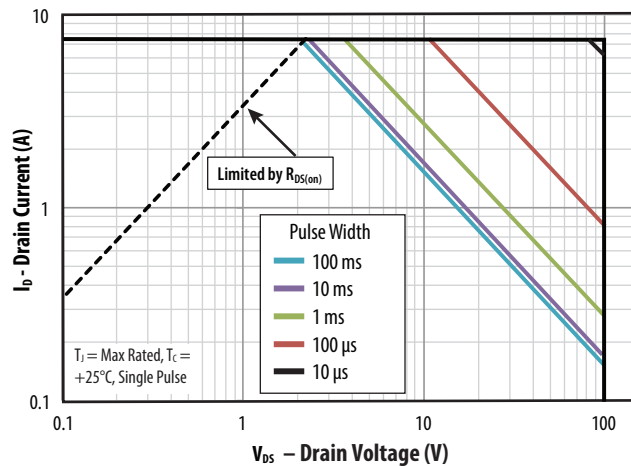
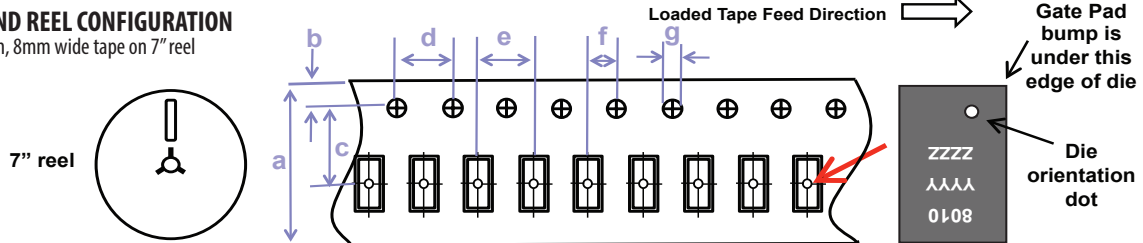


Figure 16: Safe Operating Area



TAPE AND REEL CONFIGURATION

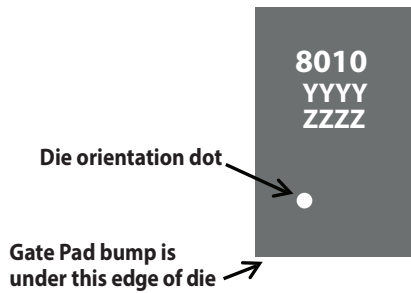
4mm pitch, 8mm wide tape on 7" reel



EPC8010 (Note 1)			
Dimension (mm)	target	min	max
a	8	7.9	8.3
b	1.75	1.65	1.85
c (see note 2)	3.5	3.45	3.55
d	4	3.9	4.1
e	4	3.9	4.1
f (see note 2)	2	1.95	2.05
g	1.5	1.5	1.6

Note 1: MSL1 (moisture sensitivity level 1) classified according to IPC/JEDEC industry standard.  
 Note 2: Pocket position is relative to the sprocket hole measured as true position of the pocket, not the pocket hole.

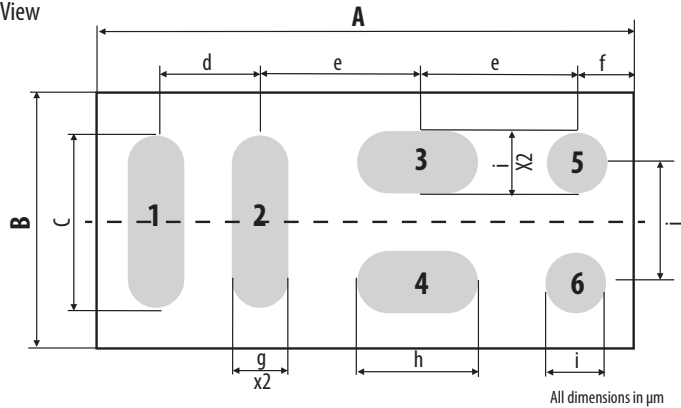
**DIE MARKINGS**



Part Number	Laser Markings		
	Part # Marking Line 1	Lot_Date Code Marking line 2	Lot_Date Code Marking Line 3
EPC8010	8010	YYYY	ZZZZ

**DIE OUTLINE**

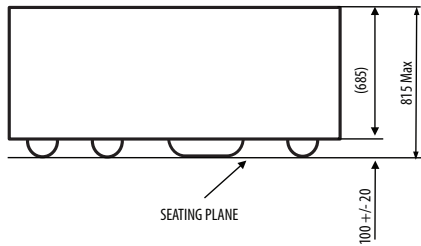
Solder Bar View



Dim	Micrometers		
	Min	Nominal	Max
A	2020	2050	2080
B	820	850	880
C	555	580	605
D	400	400	400
E	600	600	600
F	200	225	250
G	175	200	225
H	425	450	475
I	175	200	225
J	400	400	400

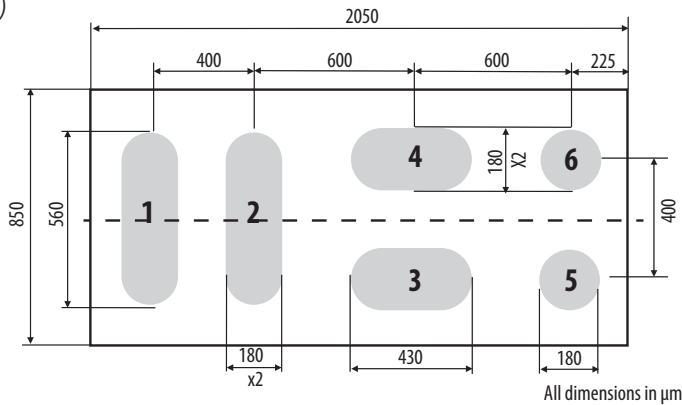
- Pad no. 1 is Gate
- Pad no. 2 is Source Return for Gate Driver
- Pad no. 3 and 5 are Source
- Pad no. 4 is Drain
- Pad no. 6 is Substrate

Side View



**RECOMMENDED LAND PATTERN**

(units in  $\mu\text{m}$ )



- Pad no. 1 is Gate
- Pad no. 2 is Source Return for Gate Driver
- Pad no. 3 and 5 are Source
- Pad no. 4 is Drain
- Pad no. 6 is Substrate

The land pattern is solder mask defined.  
Solder mask opening is 10  $\mu\text{m}$  smaller per side than bump.

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U.S. Patents 8,350,294; 8,404,508; 8,431,960; 8,436,398

Information subject to change without notice.  
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